### Advanced Nanotechnology

Chung-Ting Ke 02/19/2025 Classroom: P101, 1F, IoP Class hours: Wednesday, 09:10-12:00



### Course Syllabus

Date	Торіс	Instructor
2/19	Introduction and review	Chung-Ting Ke
2/26	Charge transport review and nanoelectronics	Chung-Ting Ke
3/5	Carbon-based nanomaterials	Chung-Ting Ke
3/12	Superconductivity	Tien-Ming Chuang
3/19	Midterm exam I	Chung-Ting Ke
3/26	Quantum transport	Chen-Hsuan Hsu
4/2	Superconducting theory and devices	Chung-Ting Ke
4/9	Magnetism and magnetoelectronics (1)	Shang Fan Lee
4/16	Magnetism and magnetoelectronics (2)	Shang Fan Lee
4/23	2D materials	Chung-Ting Ke
4/30	Thermoelectricity in nanoscale systems	Ou Min-Nan
5/07	Nano-optics	Yu-Chieh Wen
5/14	Midterm II	Chung-Ting Ke
5/21	Topological materials 1	Tien-Ming Chuang
5/28	Quantum Computation	Chung-Ting Ke
6/4	Study group oral presentation (I)	Chung-Ting Ke
6/11	Study group oral presentation (II)	Chung-Ting Ke

### Text book and Evaluation

#### Textbook:

Nanostructures and nanotechnology by Douglas Natelson, Cambridge University Press (2015) eBook available (<u>https://doi.org/10.1017/CBO9781139025485</u>) if accessed from AS domain.

Evaluation: Quiz and attendance 30% Midterm I 20% Midterm II 20% Final presentation 40%

### Let's get to know each other

<u>Chung-Ting Ke (Ting) 柯忠廷</u>

Assistant Research Fellow in the Institute of Physics and RCCI

Research Field: Quantum transport, Quantum materials Topological system, Superconducting qubit

Expertise :

Low-temperature physics, low noise electrical measurement Nanofabrication, 2D materials.



Charge transport and nanoelectronics I&II TIGP Advanced Nanotechnology Chung-Ting Ke 02/19/2025



### Charge transport and nanoelectronics

#### What is the charge transport

Charge moving—electrical response



#### Nanoelectronics

"Nano" means a scale — however, reference length scale is important!



### Outline – chapter 2-4

2.1 Free electrons
2.2 Nearly free electrons
2.3 Chemical approaches to electronic structure
2.4 More modern electronic structure methods
2.5 Lattice dynamics: phonons

3.1 Electronic types of solids
3.2 Metals
3.3 Inorganic semiconductors
3.4 Band insulators
3.5 Correlated oxides
3.6 Molecular structures

4.1 Characterization4.2 Materials growth4.3 Material removal4.4 Patterning

Nanostructures and Nanotechnology

### Outline – chapter 5-6

- **5.1 Defects**
- **5.2 Interfaces and surfaces**
- **5.3 Screening**
- **5.4 Excitons**
- **5.5 Junctions between materials**
- **5.6 Quantum wires**
- **5.7 Quantum dots**

6.1 Transport terminology
6.2 Kinetic concepts
6.3 Hall effect
6.4 Quantum transport
6.5 The classical MOSFET
6.6 State-of-the-art
6.7 Beyond CMOS

Earlier studies on metals are trying to understand electrons' behavior in metal materials • Drude model

scattering mechanism happening between ions and electrons



Where **j** is the current density,  $\sigma$  is the conductance, **E** is the electric field **n** is the charge density **m** is the electron mass and  $\tau$  is the average time constant

Ref: Ashcroft/Mermin ch1-3 and Douglas Natelson ch2

We would like to know the behavior of the electron(s)

• Free electron (Drude-Sommerfeld theory)

Simple, it can explain a lot of physics to a certain degree. Several assumptions:

$$-\frac{\hbar^2}{2m}\left(\frac{\partial^2}{\partial x^2} + \frac{\partial^2}{\partial x^2} + \frac{\partial^2}{\partial x^2}\right)\psi(r) = \varepsilon\psi(r)$$

1. the interaction of ions and electrons away from the Fermi level is neglected.

2. electron-electron interaction is neglected.

3. The outcome of collision is treated with an average collision without considering the detail of the collision.

4. the electron distribution follows the Fermi-Dirac distribution.

Despite the oversimplification, the free electron model has a great success in understanding a lot of phenomena For example density of state, heat transport, WiedemannFranz law, etc.

Ref: Ashcroft/Mermin ch2/ch3 and Natelson ch2

#### Fermi Dirac distribution

For electron gas– Maxwell distribution doesn't work, Pauli exclusion leads to a Fermi Dirac distribution

#### Density of state

For a small system, the allowed state to fill in a single particle is greatly depending on the confinement.



Ref: Ashcroft/Mermin ch2/ch3 and Natelson ch2

Degrees o freedom	of Dispersion (kinetic energy)	Density of states	Effective density of states
3 (bulk)	$E = \frac{\hbar^2}{2m^*} (k_x^2 + k_y^2 + k_z^2)$	$\rho_{\rm DOS}^{\rm 3D} = \frac{1}{2\pi^2} \left(\frac{2m^*}{\hbar^2}\right)^{\frac{3}{2}} \sqrt{E - E_{\rm C}}$	$N_{\rm c}^{\rm 3D} = \frac{1}{\sqrt{2}} \left( \frac{m^* kT}{\pi \hbar^2} \right)^{\frac{3}{2}}$
2 (slab)	$E = \frac{\hbar^2}{2m^*} (k_x^2 + k_y^2)$	$\rho_{\rm DOS}^{\rm 2D} = \frac{m^*}{\pi \hbar^2} \sigma(E - E_{\rm C})$	$N_{\rm c}^{\rm 2D} = \frac{m^*}{\pi \hbar^2} kT$
1 (wire)	$E = \frac{\hbar^2}{2m^*} (k_x^2)$	$\rho_{\text{DOS}}^{1\text{D}} = \frac{m^*}{\pi\hbar} \sqrt{\frac{m^*}{2(E-E_{\text{C}})}}$	$N_{\rm c}^{\rm 1D} = \sqrt{\frac{m^* kT}{2\pi\hbar^2}}$
0 (box)	_	$\rho_{\rm DOS}^{0\rm D}=2\delta(E-E_{\rm C})$	$N_{\rm c}^{\rm 0D} = 2$

GT, ECE course

Bloc

 $\varphi(r)$ 

h's Theorem 
$$\left(-\frac{\hbar^2}{2m}\nabla^2 + U(r)\right)\psi(r) = \varepsilon\psi(r)$$
  
=  $e^{ikr}u_k(r)$ 

U(r) = U(r+R)



In a periodic potential created by ions or valence electrons. We define a translation function  $T_R$ .

 $T_R f(r) = f(r+R) \quad T_R \varphi(r) = c(R)\varphi(r) \text{ and } c(R) = exp(ik \cdot R)$ Now, we realize that  $T_R \varphi(r) = \varphi(r+R) = exp(ik \cdot R)\varphi(r)$ And we can define  $u_k(r) = exp(-ikr)\varphi(r)$ Working out the math, we can get  $u_k(r+R) = exp(-ik(r+R))\varphi(r+R)$  $= exp(-ikr)\varphi(r) = u_k(r)$ 

Ref: Ashcroft/Mermin ch2/ch3 and Natelson ch2, Heinzel ch2

### **Band Structure**

with the simple single-particle wavefunction, we can further impose the boundary condition, a Born-von Karman B.Cs. assume periodicity happened in a direction after N<sub>i</sub> site.

$$\boldsymbol{\varphi}(r+R)$$
, let  $R = a_i N_i$ ,

*R* is also the Bravais lattice vector(recall of reciprocal lattice!)

If we use a cube lattice, we can have i=1-3, for three directions. Bloch's theorem:  $\boldsymbol{\varphi}(r+R) = \exp(ika_iN_i) = \exp(2\pi i x_iN_i) = 1$ , note  $kR = 2\pi i$ From this equality, we know that the allowed k values, Recap:

$$\mathbf{k} = \sum_{i=1}^{3} \frac{j_i}{N_i} b_i$$

The primitive lattice vector  $\mathbf{R} = \sum_{i=1}^{3} n_i a_i$ The reciprocal lattice vector  $\mathbf{G} = \sum_{i=1}^{3} n_i b_i$ 

Meaning, different to free electron case, multiple solutions!

Ref: Natelson ch2



### 1D Band Structure (König Penney model)

Now we can calculate the simple 1D band structure under a periodic potential,

 $\psi(x) = Ae^{i\alpha x} + Be^{-i\alpha x}$ Bloch's theorem  $\psi(x) = e^{ikr}u_k(x)$  $\alpha \equiv \left[\frac{2mE}{\hbar^2}\right]^{1/2},$  $u_k(x) = A e^{i(\alpha - k)x} + B e^{-i(\alpha + k)x}, \quad a > x > 0.$  $u_k(x) = C e^{i(\beta - ik)x} + D e^{-i(\beta + ik)x}, \quad -b < x < 0.$ a > x > 0. Working out the continuity conditions  $u_k(x)$ ,  $du_k(x)/dx$  and periodic in a+b  $\psi(x) = C \mathrm{e}^{\beta x} + D \mathrm{e}^{-\beta x}.$ One arrives at the energy-k relationship  $\cos(\alpha a)\cosh(\beta b) + \frac{\beta^2 - \alpha^2}{2\alpha\beta}\sin(\alpha a)\sinh(\beta b) = \cos(k(a+b)).$  $\beta \equiv \left\lceil \frac{2m}{\hbar^2} (V_0 - E) \right\rceil^{1/2},$ -b < x < 0. For E> V<sub>0</sub> and V<sub>0</sub> goes to  $\infty$  and b goes to 0,  $\frac{1}{2}\beta ab = p$  $\cos(ka) = \cos(\alpha a) + (p\sin(\alpha a))/(\alpha a)$ 

https://lampx.tugraz.at/~hadley/ss1/KronigPenney/KronigPenney.php

Natelson Ch2

### 1D Band Structure (König Penney model)

From the previous calculation, energy as the function of k:  $F(E) = \cos(k(a + b))$ For |F(E)| > 1, k will have to be imaginary, therefore, it is forbidden. Under a weak potential case and more electrons, one can arrive the 1D band structure. (See Ashcroft/Mermin ch8 to ch9)



Again, one can prove that outside the FBZ is only repeating :

$$u_{n,\mathbf{k}+\mathbf{G}}(\mathbf{r}) = \exp(\mathrm{i}(\mathbf{k}+\mathbf{G})\cdot\mathbf{r})u_{n,\mathbf{k}+\mathbf{G}}(\mathbf{r})$$
  
=  $\exp(\mathrm{i}\mathbf{k}\cdot\mathbf{r})[u_{n,\mathbf{k}+\mathbf{G}}(\mathbf{r})\exp(\mathrm{i}\mathbf{G}\cdot\mathbf{r})]$   
=  $\exp(\mathrm{i}\mathbf{k}\cdot\mathbf{r})\tilde{u}(\mathbf{r})$   
=  $\psi_{n',\mathbf{k}}(\mathbf{r}).$ 

### Other methods to calculate the band structure:

Tight-Binding model, k p theory(effective mass/spin-orbit), green function, etc. Exact band structure is much more complicated!

graphene







#### Ref: <u>http://lampx.tugraz.at/~hadley/ss1/empty/empty.php</u>

#### Density of levels and van hove singularity:

We can calculate the weighted sum over the electronic levels, like DOS in the free electron case. (A&M Ch8)

$$g_{n}(\varepsilon)d\varepsilon = \int_{S_{n}(\varepsilon)} \frac{dS}{4\pi^{3}} \delta k(\mathbf{k})$$
  

$$\delta k(\mathbf{k}) = \frac{d\varepsilon}{|\nabla \varepsilon|}$$
  

$$g_{n}(\varepsilon) = \int_{S_{n}(\varepsilon)} \frac{dS}{4\pi^{3}} \frac{1}{|\nabla \varepsilon|}$$
  
When  $|\nabla \varepsilon| = 0$  we have a  
divergence of  $dg_{n}/d\varepsilon$  is called  
van Hove singularities



Lei Wang, et al, Science Advance 2016

#### Density of levels and van hove singularity:

We can calculate the weighted sum over the electronic levels, like DOS in the free electron case. (A&M Ch8) vHs vHs

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D.I. Indolese et al PRL 2018

Metal Insulator Semiconductor Superconductor Topological material

Metal Insulator Semiconductor Superconductor Topological material



Consider e/h as quasiparticle states

with a lifetime  $\tau$ , so energy uncertainty,  $\Gamma \sim \hbar/\tau$ , to have a well-defined quasiparticles  $\Gamma \ll k_B T$ . Under certain conditions, we can treat them as non-interacting Fermi liquid.

#### Metal

Insulator Semiconductor Superconductor Topological material

Typical metal: Akali, Nobel, transition and Rare earth metals.

Yet, there are also organic metals!! 2000 Nobel prize in chemistry

#### Semimetal



Alan G. MacDiarmid Professor at the University of Pennsylvania, Philadelphia. USA. Hideki Shirakawa Professor Emeritus, University of Tsukuba. Janan. Alan J. Heeger Professor at the University of Califi

Metal Insulator Semiconductor Superconductor

Topological material

One of the key elements in many mesoscopic devices. For example, MOSFET can use high k materials for the gate dielectric, allowing a much better gate response and lower leakage.

Potential materials: HfO<sub>4</sub>Si, HfO<sub>2</sub> etc.



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A small bandgap of materials, there are direct (Ge) and indirect band gaps(Si). The gap value is in a range of 0.1 to 2 eV (300 K ~ 26 meV). Therefore, they are not very conductive at room temperature!



Metal Insulator Semiconductor Superconductor Topological material

$$n = \int_{E_{\rm C}}^{E_{\rm top}} v_{\rm e}(E) f(E, E_{\rm F}, T) dE,$$
  

$$n = \left[ 2 \left( \frac{2\pi m_{\rm e}^* k_{\rm B} T}{\hbar^2} \right)^{3/2} M_{\rm C} \right] \cdot \exp\left( -\frac{E_{\rm C} - E_{\rm F}}{k_{\rm B} T} \right)$$
  

$$= N_{\rm C}(T) \cdot \exp\left( -\frac{E_{\rm C} - E_{\rm F}}{k_{\rm B} T} \right).$$
  

$$p = \left[ 2 \left( \frac{2\pi m_{\rm h}^* k_{\rm B} T}{\hbar^2} \right)^{3/2} \right] \cdot \exp\left( -\frac{E_{\rm F} - E_{\rm V}}{k_{\rm B} T} \right)$$
  

$$= N_{\rm V}(T) \cdot \exp\left( -\frac{E_{\rm F} - E_{\rm V}}{k_{\rm B} T} \right),$$

Metal Insulator Semiconductor Superconductor Topological material

$$n_{\rm i} \equiv \sqrt{np} = \sqrt{N_{\rm C}N_{\rm V}} \cdot \exp\left(-\frac{E_{\rm g}}{2k_{\rm B}T}\right)$$

$$n_{\rm i} = 4.9 \times 10^{15} \left( \frac{m_{\rm e}^* m_{\rm h}^*}{m_0^2} \right) M_{\rm C}^{1/2} T^{3/2} \exp\left( -\frac{E_{\rm g}}{2k_{\rm B}T} \right)$$

Typical values of carrier density at 300 K: Si (10^10 cm<sup>-3</sup>), Ge(10^13 cm<sup>-3</sup>) and GaAs(10^6 cm<sup>-3</sup>) While for Cu 10^22 cm-3 (depending on the number of the outer shell electrons) To increase conductivity of semiconductor, one can add dopants.

Metal Insulator Semiconductor Superconductor Topological material

Besides elements, there are a lot of compound semiconductors.



https://www.tf.uni-kiel.de/

Metal Insulator Semiconductor Superconductor Topological material

The other is the organic semiconductors which are used in OLED/solar cell applications.



J. X. Tang et al, J. Appl. Phys. 101, (2007)



Metal Insulator Semiconductor Superconductor Topological material





Some properties:

- 1. below Tc, forming a zero DC resistance state
- 2. cooper pair is two electrons with coupling strength in the order of superconducting gap.
- 3. Meissner effect, the magnetic field lines exclusion effect

Metal Insulator Semiconductor Superconductor Topological material

Important theory for SC: highly recommended books for superconductivity

#### Theory of Superconductivity

Tfy-3.4801 (6 cr.) P, I–II. Aalto University, School of Science and Technology Department of Applied Physics Fall, 2010

N. B. Kopnin Low Temperature Laboratory, Aalto University email: kopnin@boojum.hut.fi August 26, 2010

# INTRODUCTION TO SUPERCONDUCTIVITY SECOND EDITION

#### MICHAEL TINKHAM

Metal Insulator Semiconductor Superconductor Topological material

Type of superconductors:

Type I Type II



R. G. Sharma

Metal Insulator Semiconductor Superconductor Topological material

Type of superconductors:

High Tc superconductors



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Type of superconductors:

s-wave d-wave p-wave?

#### Order parameter symmetry



https://rdreview.jaea.go.jp/tayu/ACT97E/01/0104.htm

Metal Insulator Semiconductor Superconductor Topological material

Bogoliubov-de Gennes equations A theory to describe excitation spectrum for inhomogeneous superconductors the BCS wave function for the electron (u) and hole (v) in the excitations

$$\Psi^{\dagger}(\mathbf{r}\uparrow) = \sum_{n} \left[\gamma_{n\uparrow}^{\dagger} u_{n}^{*}(\mathbf{r}) - \gamma_{n\downarrow} v_{n}(\mathbf{r})\right]$$
$$\Psi^{\dagger}(\mathbf{r}\downarrow) = \sum_{n} \left[\gamma_{n\downarrow}^{\dagger} u_{n}^{*}(\mathbf{r}) + \gamma_{n\uparrow} v_{n}(\mathbf{r})\right]$$

$$H_{eff} = \int dV \left\{ \sum_{s} \psi_{s}^{\dagger} H_{0} \psi_{s} + \Delta(\mathbf{r}) \psi_{\uparrow}^{\dagger} \psi_{\downarrow}^{\dagger} + \Delta^{*}(\mathbf{r}) \psi_{\downarrow} \psi_{\uparrow} \right\}$$

$$H_0 = \frac{1}{2m} \left( \mathbf{p} + \frac{e}{c} \mathbf{A} \right)^2 + U(\mathbf{r}) - \mu,$$

Metal Insulator Semiconductor Superconductor **Topological material** 

Bogoliubov-de Gennes equations A theory to describe excitation spectrum for inhomogeneous superconductors

 $i\psi$ 

 $i\psi$ 

$$\begin{split} H_{eff} &= \sum_{ns} E_n \gamma_{ns}^{\dagger} \gamma_{ns}, \\ \{\gamma_{ns}, \gamma_{n's'}^{\dagger}\} = \delta_{nn'} \delta_{ss'}, \\ \text{Use the relationship:} \\ \{\gamma_{ns}, \gamma_{n's'}\} = \delta_{nn'} \delta_{ss'}, \\ \{\gamma_{ns}, \gamma_{n's'}\} = 0. \\ i\dot{\gamma}_{ns} &= [\gamma_{ns}, H_{eff}] = E_n \gamma_{ns}, \\ i\dot{\gamma}_{ns}^{\dagger} &= [\gamma_{ns}^{\dagger}, H_{eff}] = -E_n \gamma_{ns}^{\dagger}. \\ i\dot{\psi}_{\uparrow}(\mathbf{r}) &= [\psi_{\uparrow}(\mathbf{r}), H_{eff}] = H_0 \psi_{\uparrow}(\mathbf{r}) + \Delta(\mathbf{r}) \psi_{\downarrow}^{\dagger}(\mathbf{r}) \\ i\dot{\psi}_{\downarrow}(\mathbf{r}) &= [\psi_{\downarrow}(\mathbf{r}), H_{eff}] = H_0 \psi_{\downarrow}(\mathbf{r}) - \Delta(\mathbf{r}) \psi_{\uparrow}^{\dagger}(\mathbf{r}) \end{split}$$

•

Metal Insulator Semiconductor Superconductor Topological material

Bogoliubov-de Gennes equations A theory to describe excitation spectrum for inhomogeneous superconductors

$$H_0 u_n(\mathbf{r}) + \Delta(\mathbf{r}) v_n(\mathbf{r}) = E_n u_n(\mathbf{r}),$$
$$H_0^* v_n(\mathbf{r}) - \Delta^*(\mathbf{r}) u_n(\mathbf{r}) = -E_n v_n(\mathbf{r}).$$

The BdG equation:

$$\begin{pmatrix} H_0 & \Delta \\ \Delta^* & -H_0^* \end{pmatrix} \begin{pmatrix} u_n \\ v_n \end{pmatrix} = E_n \begin{pmatrix} u_n \\ v_n \end{pmatrix}$$

$$\Delta(\mathbf{r}) = -V_e \langle \psi_{\downarrow}(\mathbf{r})\psi_{\uparrow}(\mathbf{r})\rangle$$

Note:  $\Delta = 0$ , we return to ordinary e/h eigenfunction, however,  $\Delta$  is the function of u and v
#### Andree reflection:



For the N side  $\Delta = 0$ :

$$\begin{pmatrix} U(x) \\ V(x) \end{pmatrix}_{L} = e^{i\lambda_{N}x} \begin{pmatrix} 1 \\ 0 \end{pmatrix} + ae^{-i\lambda_{N}x} \begin{pmatrix} 0 \\ 1 \end{pmatrix}$$
$$\lambda_{N} = \frac{\epsilon}{\hbar v_{x}}$$
Incident electron reflection hole

For the S side(if  $\varepsilon > \Delta$ ) :

$$\begin{pmatrix} U(x) \\ V(x) \end{pmatrix}_{R} = c e^{i\lambda_{S}x} \begin{pmatrix} U_{0} \\ V_{0} \end{pmatrix} \qquad \lambda_{S} = \frac{\sqrt{\epsilon^{2} - |\Delta|^{2}}}{\hbar v_{x}}$$

 $\rm U_{0}$  and  $\rm V_{0}$  satisfy the following relationship

$$U_0^2 - V_0^2 = \frac{\sqrt{\epsilon^2 - |\Delta|^2}}{\epsilon}, \ U_0 V_0 = \frac{|\Delta|}{2\epsilon}$$

$$a = V_0/U_0, \ c = 1/U_0 \qquad |a|^2 + (U_0^2 - V_0^2)|c|^2 = 1$$
if  $\epsilon < \Delta$ 

$$\tilde{c} = 1 \left( 1 - \sqrt{|\Delta|^2 - \epsilon^2} \right) \quad \tilde{c} = 1 \left( 1 - \sqrt{|\Delta|^2 - \epsilon^2} \right)$$

$$\tilde{U}_0 = \frac{1}{\sqrt{2}} \left( 1 + i \frac{\sqrt{|\Delta|^2 - \epsilon^2}}{\epsilon} \right) , \ \tilde{V}_0 = \frac{1}{\sqrt{2}} \left( 1 - i \frac{\sqrt{|\Delta|^2 - \epsilon^2}}{\epsilon} \right)$$

 $a = \tilde{V}_0 / \tilde{U}_0 , \ c = 1 / \tilde{U}_0$   $|a|^2 = 1$ 

Metal Insulator Semiconductor Superconductor Topological material

Some materials are expected to be boring band insulators, however, it turns out they have very unique band structure at the boundaries.

One material family for example is the topological insulators such as Bi<sub>2</sub>Se<sub>3</sub>, HgTe/CdTe heterostructure etc.



Yoshinori Tokura et al, Nature Review Physics (2019)

Metal Insulator Semiconductor Superconductor Topological material

### **The Nobel Prize in Physics 2016**



Ill: N. Elmehed. © Nobel Media 2016 David J. Thouless Prize share: 1/2 Ill: N. Elmehed. © Nobel Media 2016 F. Duncan M. Haldane Prize share: 1/4



Ill: N. Elmehed. © Nobel Media 2016 J. Michael Kosterlitz Prize share: 1/4

Metal Insulator Semiconductor Superconductor Topological material

Another way to look at the substances is based on the symmetries. The symmetry class is from the Lei group definition and the periodic table shows their symmetry/topological invariant.

T: 0, 1 and -1, P: 0, 1 and -1, C:0

#### Altland and Zirnbauer (1996)

$\mathbf{class}$	С	${\cal P}$	${\mathcal{T}}$	d=0	1	<b>2</b>	3
Α				$\mathbb{Z}$		$\mathbb{Z}$	
AI			1	$\mathbb{Z}$			
AII			-1	$2\mathbb{Z}$		$\mathbb{Z}_2$	$\mathbb{Z}_2$
AIII	1				$\mathbb{Z}$		$\mathbb{Z}$
BDI	1	1	1	$\mathbb{Z}_2$	$\mathbb{Z}$		
$\mathbf{C}$		-1				$2\mathbb{Z}$	
$\mathbf{CI}$	1	-1	1				$2\mathbb{Z}$
$\mathbf{CII}$	1	-1	-1		$2\mathbb{Z}$		$\mathbb{Z}_2$
D		1		$\mathbb{Z}_2$	$\mathbb{Z}_2$	$\mathbb{Z}$	
DIII	1	1	-1		$\mathbb{Z}_2$	$\mathbb{Z}_2$	$\mathbb{Z}$

https://topocondmat.org/w8\_general/classification.html https://math.ucr.edu/home/baez/tenfold.html

Metal Insulator Semiconductor Superconductor Topological material

- Metal with broken time-reversal symmetry: "Unitary" class A
- Spinless time-reversal invariant superconductor: class BDI
- Spin-1/2 superconductor with no physical symmetries: Class D

#### Altland and Zirnbauer (1996)

class	С	$\mathcal{P}$	$\mathcal{T}$	d = 0	1	2	3
A				Z		$\mathbb{Z}$	
AI			1	$\mathbb{Z}$			
AII			-1	$2\mathbb{Z}$		$\mathbb{Z}_2$	$\mathbb{Z}_2$
AIII	1				$\mathbb{Z}$		$\mathbb{Z}$
BDI	1	1	1	$\mathbb{Z}_2$	$\mathbb{Z}$		
$\mathbf{C}$		-1				$2\mathbb{Z}$	
$\mathbf{CI}$	1	-1	1				$2\mathbb{Z}$
CII	1	-1	-1		$2\mathbb{Z}$		$\mathbb{Z}_2$
D		1		$\mathbb{Z}_2$	$\mathbb{Z}_2$	$\mathbb{Z}$	
DIII	1	1	-1		$\mathbb{Z}_2$	$\mathbb{Z}_2$	$\mathbb{Z}$

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Charge transport and nanoelectronics II TIGP Advanced Nanotechnology Chung-Ting Ke 02/26/2025



### **Different dimensions**



Teich, M.C. and B. Saleh, Fundamentals of photonics (1991)

### Length scales

dimensions	coordinate region	spacing in <i>k</i>	Fermi region	number of electron, electron density, Fermi wave length N=Fermi region/spacing in k, $\lambda_F=2\pi/k_F$		
1	Length L	$2\pi/L$	$2k_F$	$N = \frac{4k_F}{2\pi/L}$	$n = \frac{N}{L} = \frac{4k_F}{2\pi}$	$\lambda_F = rac{4}{n}$
2	Area L <sup>2</sup>	$(2\pi/L)^2$	$\pi k_F^2$	$N = \frac{2\pi k_F^2}{(2\pi/L)^2}$	$n = \frac{N}{L^2} = \frac{k_F^2}{2\pi}$	$\lambda_F = \left(\frac{2\pi}{n}\right)^{1/2}$
3	Volume L <sup>3</sup>	$(2\pi/L)^{3}$	$\frac{4}{3}\pi k_F^3$	$N = \frac{2(4\pi k_F^3/3)}{(2\pi/L)^3}$	$n = \frac{N}{L^3} = \frac{k_F^3}{3\pi^2}$	$\lambda_F = 2 \left(\frac{\pi}{3n}\right)^{1/3}$

#### Mean Free Path

Prude model: 
$$J = \sigma E = \frac{ne^2\tau}{m}E$$
  
 $J = nev$   
Drift velocity  
Alean scattering time

$$\tau = \frac{m}{e} \frac{v}{E} = \frac{m\mu}{e}$$
 Electron mobility

$$l_e = v_F \tau = \frac{\hbar k_F}{m} \frac{m\mu}{e} = \frac{\hbar \mu}{e} \mathbf{k}_F$$

Dimension	Fermi wavelength	Mean free path
1	$\lambda_F = rac{4}{n}$	$l_e = \frac{\hbar\mu}{e} \frac{n\pi}{2}$
2	$\lambda_F = \left(\frac{2\pi}{n}\right)^{1/2}$	$l_e = \frac{\hbar\mu}{e}\sqrt{2\pi n}$
3	$\lambda_F = 2 \left(\frac{\pi}{3n}\right)^{1/3}$	$l_e = \frac{\hbar\mu}{e} (3n)^{1/3} \pi^{2/3}$

#### Diffusion coefficient

Diffusive current flow:  $J=-D\nabla n$  (due to the density gradient ), D is the diffusion constant

Einstein relation (Brownian motion):

 $l_e = v_F \tau$ 

$$D = \frac{\mu k_B T}{e}$$

$$\sigma = \frac{ne^2\tau}{m} = ne\mu \Rightarrow \mu = \frac{e\tau}{m}$$

Dimension	Equipartition theorem	Diffusion constant
1	$\frac{1}{2}mv_F^2 = \frac{1}{2}k_BT$	
2	$\frac{1}{2}mv_F^2 = k_B T$	$D = \frac{l_e v_F}{d}, d = 1,2,3$
3	$\frac{1}{2}mv_F^2 = \frac{3}{2}k_BT$	

Diffusion vs. Ballistic  $l_e = v_F \tau$ -2 W Diffusive (>)
<sup>6q</sup> −6  $l_e \ll W$  and L -8 Ballistic (2020) $l_e > W$  and L QPC 1/3 R (h/2e<sup>2</sup>) 5/1 1/6  $l_e \gg W$  and L 1/8 1/10

#### Fabry-Perot oscillations



Peter Rickhaus et al. Science Advances (2020)



Heinzel

#### Thouless Energy: E<sub>Th</sub>



Here, one can consider a diffusive system with size L, the quantum levels have a spacing of  $\varepsilon = 1/N(\varepsilon_F) \cdot L^d$ .



In the diffusive system, another characteristic energy scale is the Thouless energy  $E_{Th} = \frac{\hbar D}{L^2}$ , it can be considered as the traveling time (depending on the diffusion time) through the system.

#### Thouless Energy: E<sub>Th</sub>

Here, one can consider a diffusive system with size L, the quantum levels have a spacing of  $\varepsilon = 1/N(\varepsilon_F) \cdot L^d$ .



 $\underbrace{\downarrow}_{T} E = \frac{\hbar}{\tau}$  In the diffusive system, another characteristic energy  $E_{Th} = \frac{\hbar D}{L^2}$ , it can be considered as the traveling time (depending on the diffusion time) through the system.

Conductance (Einstein relation)  $G = \sigma L^{d-2} = \frac{e^2 N(\varepsilon_F) L^d D}{L^2} = \sigma_0 g(L)$  where  $\sigma_0 = \frac{e^2}{\hbar}$ and  $g(L) = \frac{\hbar D/L^2}{1/N(\varepsilon_F) L^d} = \frac{E_{Th}}{\varepsilon}$  (dimensionless Thouless conductance)  $g(L) < 1 \ (R > \frac{\hbar}{e^2}) \Rightarrow$  localized state  $g(L) = > 1 \ (R < \frac{\hbar}{e^2}) \Rightarrow$  extended state



#### Anderson localization

 $g(L) < 1 \Rightarrow$  localized state  $G \propto e^{-L/\xi}$  $g(L) > 1 \Rightarrow$  extended state  $G \propto L^{d-2}$ 

#### Anderson model



Boris Altshuler lecture

localized



Lattice is considered with the Tight binding Random on-site energy on the lattice Only the nearest-neighbor hopping.

As the result, the will be a critical value, Ic I<Ic (localized, insulator) I>Ic (extended, metal)

#### Anderson localization



#### Mordechai Segev et al, Nature Photonics (2013)

Anderson localization

Scaling theory of localization, dimensionless g is function of L



 $\frac{d\log(g)}{d\log(L)} = \beta(g)$ 

It's universal and material independent. It only matters with global symmetry.

Metal-insulator transition in 3D case but all states in 2D and 1D are localized.

Phase Coherence Length

 $l_{\phi}$  phase breaking length

$$L_{\varphi} = V_F \tau_{\varphi} \qquad L_{\varphi} = \sqrt{D\tau_{\varphi}}$$

Phase-breaking :

Collisions between electrons, electron-phonon scattering Collisions with impurities that have an internal degree of freedom

Dimension	Note: (1) Dimensionality in terms of $l_{\phi}$ (2) $l_{\phi} > l$ Localization correction $\delta\sigma$ to the Drude conductivity
1	$\delta\sigma_{1D} = -\frac{e^2 L_{\varphi}}{\pi\hbar}$
2	$\delta\sigma_{2D} = -\frac{e^2}{2\pi^2\hbar} \ln\frac{L_{\varphi}}{l}$
3	$\delta\sigma_{3D} = -\frac{e^2}{2\pi^2\hbar} \left[\frac{1}{l} - \frac{1}{L_{\varphi}}\right]$

Weak localization (disorder system)



(b) Weak localization  

$$1400$$
  
 $1380$   
 $1360$   
 $1360$   
 $1340$   
 $1320$   
 $-2.0 -1.5 -1.0 -0.5$   
 $-2.0 -1.5 -1.0 -0.5$   
 $1.0 -0.5 + 0.5 + 0.1 + 0.5 + 0.0 + 0.0 + 0.$ 

Classical Quantum diffusion interference  $W_{a \to b} = \left| \sum_{i} A_{i} \right|^{2} = \sum_{i} |A_{i}|^{2} + \sum_{i \neq j} A_{i} A_{j}^{*}$ 

In zero field, B=0,  $A_{+}=A_{-}=A$ 

Probability for back-scattering:

$$W_{0 \leftrightarrow 0} = |A_{+} + A_{-}|^{2} = 4|A|^{2}$$

The probability of returning to the same position becomes higher. This means lower conductance thus higher resistance.

#### Weak anti-localization

A disordered system is under the influence of spin-orbit interaction which diminishes the localization due to spin processes. Now, the conductance is enhanced instead lower. Under a certain scenario, the conductance correction:



Only cubic term  $\begin{aligned} \Delta\sigma(B) - \Delta\sigma(0) &= \frac{e^2}{2\pi^2\hbar} \left\{ \Psi \left( \frac{1}{2} + \frac{H_{\varphi}}{B} + \frac{H_{SO}}{B} \right) \right. \\ &+ \frac{1}{2} \Psi \left( \frac{1}{2} + \frac{H_{\varphi}}{B} + 2\frac{H_{SO}}{B} \right) \\ &- \frac{1}{2} \Psi \left( \frac{1}{2} + \frac{H_{\varphi}}{B} \right) - \ln \frac{H_{\varphi} + H_{SO}}{B} \\ &- \frac{1}{2} \ln \frac{H_{\varphi} + 2H_{SO}}{B} + \frac{1}{2} \ln \frac{H_{\varphi}}{B} \right\}. \end{aligned}$ 

Only linear term  $\Delta\sigma(B) - \Delta\sigma(0) =$   $\frac{e^2}{2\pi^2\hbar} \left\{ \Psi \left( \frac{1}{2} + \frac{H_{\varphi}}{B} \right) - \ln \frac{H_{\varphi}}{B} \right\}$ This allows us to

study the spin-orbit effect of the system.

Quantum phase under a field

In a field  $B=\nabla \times A$ 

Canonical momentum

p = mv - eA

Magnetic field: break the time reversal symmetry

electrons pick a phase  $\phi$  when traveling along with a path P



phase difference between two paths with the same ends

$$\begin{split} \delta\varphi &= \frac{1}{\hbar} \int_{P}^{Q} p_{u} \cdot dl_{1} - \frac{1}{\hbar} \int_{P}^{Q} p_{d} \cdot dl_{2} = \frac{1}{\hbar} \int_{P}^{Q} p_{u} \cdot dl_{1} + \frac{1}{\hbar} \int_{Q}^{P} p_{d} \cdot dl_{2} = \frac{1}{\hbar} \oint p \cdot dl \\ &= \frac{e}{\hbar} \int (\nabla \times A) \cdot dS = \frac{e}{\hbar} \int BdS = 2\pi \frac{B \cdot S}{h/e} \\ & \text{acquired phase} \\ & \text{around a loop} \end{split}$$

Magnetic length:

#### Cyclotron motion

#### In a magnetic field



Cyclotron frequency  $F = evB = mr_c \omega_c^2$ 

Cyclotron radius 
$$r_c \omega_c = v_F \longrightarrow r_c = \frac{v_F}{\omega_c} = \frac{mv_F}{eB} = \frac{\hbar k_F}{eB}$$

 $I_B$  = magnetic length

flux quantization  

$$B \cdot \pi r_c^2 = n\Phi_0 = \frac{nh}{e} \longrightarrow r_c = \sqrt{\frac{2n\hbar}{eB}} \equiv \sqrt{2n} l_B$$
 $2\pi l_B^2 \cdot B = \Phi_0$ 

$$B = \frac{\hbar^2 k_F^2}{2ne\hbar} = \frac{mE_F}{ne\hbar} \longrightarrow \text{Quantizing magnetic field}_{He}$$

Heinzel, Ch 5.4, p.143

#### Quantum Hall effect



#### 2D electron gas

In a quantum well type structure, the potential well confines electrons/holes in a 2D plane. Charges only allow moving in the X-Y plane

Another type is real 2d material such as graphene or transition metal dichalcogenide





#### Quantum Hall effect

Developing high mobility samples has a long history, GaAs quantum wells.

It took almost three decades to boost the mobility from 10k to 10 M cm<sup>2</sup>/Vs along with this development amazing physics was discovered.



Quantum Hall effect, Nobel prize 1985





Fractional quantum Hall effect, Nobel prize 1998



#### Quantum Hall effect

Landau quantization(David Tong, The Quantum Hall effect):

$$H = \frac{1}{2m} (\mathbf{p} + e\mathbf{A})^2 \qquad \nabla \times \mathbf{A} = B\hat{\mathbf{z}}$$

$$[x_i, p_j] = i\hbar\delta_{ij}$$
 with  $[x_i, x_j] = [p_i, p_j] = 0$ 

The mechanical momentum  $\pi = \mathbf{p} + e\mathbf{A} = m\dot{\mathbf{x}}$ 

$$\{m\dot{x}_{i}, m\dot{x}_{j}\} = \{p_{i} + eA_{i}, p_{j} + eA_{j}\} = -e\left(\frac{\partial A_{j}}{\partial x^{i}} - \frac{\partial A_{i}}{\partial x^{j}}\right) = -e\epsilon_{ijk}B_{k}$$

$$a = \frac{1}{\sqrt{2e\hbar B}}\left(\pi_{x} - i\pi_{y}\right) \quad \text{and} \quad a^{\dagger} = \frac{1}{\sqrt{2e\hbar B}}\left(\pi_{x} + i\pi_{y}\right)$$

$$[a, a^{\dagger}] = 1 \qquad H = \frac{1}{2m}\boldsymbol{\pi} \cdot \boldsymbol{\pi} = \hbar\omega_{B}\left(a^{\dagger}a + \frac{1}{2}\right)$$





#### Quantum Hall effect



Kim et al. Nat. Commun. (2021)

Yacoby's group Science (2012)

Fractional quantum Hall effect

#### Quantum wire(1D)



Conductance is a fixed value regardless of the length of the wire.

*Jesper Nygård* Lecture note

### Quantum wire(1D)



### Quantum dot (OD system)

1D wire with two identical barriers under a **coherent transport** 

$$\xrightarrow{t} r \xleftarrow{t} \frac{t}{}$$

$$t = |t|e^{i\phi_t}$$
$$r = |r|e^{i\phi_r}$$

Total transmission:

$$T_{\text{total}} = \frac{|t|^4}{1 + |r|^4 - 2|r|^2 \cos(\phi)}, \quad \phi = 2kL + \phi_{r1} + \phi_{r2}$$

For the resonant transmission(round trip with a phase of  $2\pi n$ ):

For 
$$\phi = 2\pi n$$
:  $T_{\text{total}} = \frac{|t|^4}{(1-|r|^2)^2} = \frac{T^2}{(1-R)^2} = \frac{T^2}{T^2} = 1$ 

Resonance condition: kL= πn



*Jesper Nygård* Lecture note

Resulting in a total transmission even  $T=|t|^2<1$  for individual barriers

#### Quantum dot (OD system)



Total transmission:

$$T_{\text{total}} = \frac{|t_1|^2 |t_2|^2}{1 - |r_1|^2 |r_2|^2}$$

The resistance is like resistors in series:

Resistance = 
$$\frac{h}{2e^2} \left( 1 + \frac{|r_1|^2}{|t_1|^2} + \frac{|r_2|^2}{|t_2|^2} \right)$$

*Jesper Nygård* Lecture note

#### Scattering matrix:

$$\mathbf{b} = \tilde{S} \cdot \mathbf{a}. \quad \begin{pmatrix} b_1 \\ b_2 \end{pmatrix} = \begin{pmatrix} r & t' \\ t & r' \end{pmatrix} \begin{pmatrix} a_1 \\ a_2 \end{pmatrix}$$

$$1 \begin{array}{c} a_{1r} \longrightarrow \\ b_{1r} \longrightarrow \\ 2 \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array} \begin{array}{c} a_{2r} \longrightarrow \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ \end{array}$$

$$\begin{pmatrix} d_{1r} \\ d_{2r} \\ b_{1l} \\ b_{2l} \end{pmatrix} = S_{L} \begin{pmatrix} a_{1r} \\ a_{2r} \\ c_{1l} \\ c_{2l} \end{pmatrix} \qquad \begin{pmatrix} c_{1r} \\ c_{2r} \\ c_{1l} \\ c_{2l} \end{pmatrix} = S_{N} \begin{pmatrix} d_{1r} \\ d_{2r} \\ d_{1l} \\ d_{2l} \end{pmatrix} \qquad \begin{pmatrix} b_{1r} \\ b_{2r} \\ d_{1l} \\ d_{2l} \end{pmatrix} = S_{R} \begin{pmatrix} c_{1r} \\ c_{2r} \\ a_{1l} \\ a_{2l} \end{pmatrix}$$

$$\begin{pmatrix} b_{1r} \\ b_{2r} \\ b_{2l} \\ b_{2l} \end{pmatrix} = S_{R} \begin{pmatrix} a_{1r} \\ a_{2r} \\ a_{1l} \\ a_{2r} \\ a_{1l} \end{pmatrix} = \begin{pmatrix} t_{1r,1r} t_{1r,2r} r_{1r,1l} r_{1r,2l} \\ t_{2r,1r} t_{2r,2r} r_{2r,1l} r_{2r,2l} \\ r_{1l,1r} r_{1l,2r} r_{1l,2l} \\ a_{1l} \\ a_{2l} \end{pmatrix}$$

$$\left(\mathbf{b}_{2i}\right) = \left[\mathbf{a}_{2i}\right] = \left[\mathbf{r}_{2i,1r} \mathbf{r}_{2i,2r} \mathbf{t}_{2i,1r} \mathbf{t}_{2i,2r}\right] \left(\mathbf{a}_{2r}\right)$$

#### Quantum dot (OD system)



Total transmission:

$$T_{\text{total}} = \frac{|t_1|^2 |t_2|^2}{1 - |r_1|^2 |r_2|^2}$$

The resistance is like resistors in series:

Resistance = 
$$\frac{h}{2e^2} \left( 1 + \frac{|r_1|^2}{|t_1|^2} + \frac{|r_2|^2}{|t_2|^2} \right)$$

*Jesper Nygård* Lecture note

#### Scattering matrix:

$$\mathbf{b} = \tilde{S} \cdot \mathbf{a}. \quad \begin{pmatrix} b_1 \\ b_2 \end{pmatrix} = \begin{pmatrix} r & t' \\ t & r' \end{pmatrix} \begin{pmatrix} a_1 \\ a_2 \end{pmatrix}$$

$$1 \begin{array}{c} a_{1r} \longrightarrow \\ b_{1r} \longleftarrow \\ c_{1r} \longrightarrow \\ d_{1r} & d_{1r} \\ a_{2r} \longrightarrow \\ b_{2r} \longrightarrow \\ b_{2r} & d_{2r} \\ c_{2r} \longrightarrow \\ b_{2r} & d_{2r} \\ c_{2r} & b_{2r} \\ c_{2r} & c_{2r} \\ c_{2r} &$$



Quantum dot (single electron transition)



The total charge on the island  $Q = Q_2 - Q_1 - Q_G$  Where,  $Q_G = C_G(V_G - V_2)$ The voltage drop on each junctions (barriers)  $V_1 = \frac{1}{C_{\text{tot}}} \left( (C_{\text{G}} + C_2) V_{\text{DS}} - C_{\text{G}} V_{\text{G}} + ne \right),$  $V_2 = \frac{1}{C_{\text{tot}}} \left( C_1 V_{\text{DS}} + C_G V_G - ne \right).$ Total energy for  $\Delta E_{\text{tot}} = \frac{e}{C_{\text{tot}}} \left( \frac{e}{2} + (en + (C_2 + C_G)V_{\text{DS}} - C_G V_G) \right)$ adding e from left  $\mp [en + (C_{\rm G} + C_2)V_{\rm DS} - C_{\rm G}V_{\rm G}] > \frac{e}{2} \quad \text{or} \\ \pm [en - C_1V_{\rm DS} - C_{\rm G}V_{\rm G}] > \frac{e}{2}.$ The conditions for tunneling one electron



Quantum dot (single electron transition)



The conditions create the charge stability diagram. If we only consider a one-level system.



Jiwoong Park Ph.D. thesis (2003)

Quantum dot (single electron transition)


# Electron transport

Quantum dot (single electron transition)





Spin related cotunneling process: Kondo effect





P. Jarillo-Herrero et al. Nature (2005)

### Quizs

1. What is the mean free path?

#### 2. which is diffusive and which is ballistic А



В

How to manipulate materials

How to make materials?

To be honest, it is very complicated!!

These are examples of two materials (Au and Ag) coming from mining. For other materials, there are a lot of different processes for various metals.



Adapted from Quora



**Physical Vapor Deposition** 

Sputtering



#### Evaporation



#### **Chemical Vapor Deposition**

Unlike the previous PVD, here we utilize the chemical reaction of gaseous chemicals (precursor compounds) at different temperatures for which chemicals may decompose then react in situ.

The sample can be grown on a substrate with a catalyst as the nucleation center. Often consider as an easy but dirty method.



Olga Zaytseva et al. DOI:10.1186/s40538-016-0070-8

Plasma-Enhanced Chemical Vapor Deposition (PECVD)

Plasma reduces the required temperature

for precursors, less power consumption.



Onno Gabriel et al. EPJ Photovoltaics (2014)



Applied Materials

#### Atomic Layer Deposition (ALD)

- A layer by layer growth process
- Very slow but good coverage





Samsung DRAM

http://dx.doi.org/10.1117/2.1201204.004218

#### Molecular beam epitaxy (MBE)





• Atomically layer by layer growth

process

- Very slow but extremely high quality
- UHV system, very expensive

Material Removing techniques

One can classify them into:

Chemical remove

Physical remove

Physical Chemical remove

#### Chemical remove

A wet process, one can use chemicals to remove the unwanted materials.

Take SiO2 as an example:



Etching rate(BOE\_7:1): to SiO2 80 nm/min at 20 C, to Si is almost zero, how about mask??

#### Physical remove

A dry etching process, use gas particle in a plasma environment to form ion bombardment on the material surface.



Etching rate: the same for everyone, therefore carefully calibration or endpoint detection is important

#### **Chemical and Physical remove**

A combined process uses ions to enhance the chemical reaction.

#### **Reactive Ion Etching**



Chemical and Physical remove Inductively Coupled Plasma-RIE etch





For high aspect ratio or VIA hole, Bosch process is needed



⊕ ↓ U

First Etch

Passivate

Start of Second Etch

Second Etch Continues

C. J. D. Craigie et al http://dx.doi.org/10.1116/1.1515910

#### **Chemical and Physical remove**

Advanced etching technique is important!!!



AZoNano.com/Oxford

1.70KX 5.88M 0324

09KU

Haruhiko ABE et al. JJAP (2008)

How to create the MASK: the workflow for lithography







0.21 µm

0.44 µm

DoF (assuming  $k_2 = 1$ )

Diagram by Nikkei Electronics based on materials from Intel, International Technology Roadmap for Semiconductors (ITRS), etc. http://www.newmaker.com/news 41958.html

#### ASML EUV system NXE:3400B (ref: ASML website)



#### e-beam lithography

- •No mask is needed! (both pros and cons)
- •the wavelength of electrons can be controlled, therefore fine structures can be realized.
- However, compared to photolithography, it is a much slower process.
- Incident electron energy, current can control the spot size of the beam, therefore, influence the feature as well as speed.
- It is very useful in research but not industry.









- Good for the prototype test 1.
- Thin resist line-width < 30nm 2.
- Clear align key image 3.
- Good for lift-off process 4.
- Lack of stage stability 5.



- Good for large-area exposure
- Thin resist line-width < 10nm
- 3. Require thick/clear align keys
- Require extra resist engineering 4.
- Stable/accurate stage stability 5.





楊富量 (NDL), Outlook for 15nm CMOS Manufacture



M. Muraki et al. J. Vac. Sci. Technol. B 18(6), 3061, 2000, *Canon Inc.*,

#### E-beam lithography

One also needs to generate the patterns for which you would like the e-beam system to write.

There is a lot of software for this purpose such as AutoCAD, K-layout, DesignCAD, etc...



E-beam lithography

Beam voltage: 50- 150 kV Beam current: 10<sup>th</sup> pA to 800 nA Field size: 0.5x 0.5 to 300x300 mm<sup>2</sup>



Dan Meisburger et al. doi.org/10.1116/1.4931589







#### Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,

SEM/TEM



Idea of Styli profilometer

Atomic Force Microscope

https://probe.olympus-global.com/en/product/spm/

#### Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,

SEM/TEM



Source: Bruker, Park



Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,

SEM/TEM



https://ayscomdatatec.com/en/probe-stations/



https://www.photonicsonline.com/

One can measure C-V, I-V, thermal properties, etc.

Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,









Transmission Characterizations: photographic plate AFM, crystal profilometer, X-rays electrical measurement, diffracted beams difraction pattern X-ray, Spring 8 Photoluminescence, Synchrotron radiation produced at SPring-8 Vacuum Raman spectrum, Infrared light Visible light Ultraviolet light ultraviolet light Soft X-rays X-rays Terahertz light Hard X-rays 100 µm 100 nm 10 nm 0.1 nm 10 µm 1 nm ARPES, - Wavelength of light — → Shorter Longer + SEM/TEM Virus Protein Carbon nanotube Atom Hair Bacteria

Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence, Raman spectrum, ARPES,

SEM/TEM







Phuong Vuong, thesis

Raman, an inelastic process in which photon electron transfer to molecule



Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence, Raman spectrum, ARPES,

*ћ* (eV)

SEM/TEM



T. O. Wehling et al, DOI:10.1080/00018732.2014.927109 (2014)

0.2

0.3

Characterizations: AFM, profilometer, electrical measurement, X-ray, Photoluminescence,

Raman spectrum,

ARPES,





https://anapath.ch/electron-microscopy-2/

Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,





https://orslabs.com/services/materialanalysis/sem/



#### Bert Weckhuysen / Utrecht University



https://www.huttonltd.com/services/scanningelectron-microscopy-sem
## Nanofabrication

## Characterizations:

AFM,

profilometer,

electrical measurement,

X-ray,

Photoluminescence,

Raman spectrum,

ARPES,





PbS nanocrystals as imaged via TEM

Hf

